Electron correlation and charge transfer at the Ni/Co interface

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The evolving magnetism and electronic structure at the Ni/Co interface have been studied using x-ray absorption spectroscopy (XAS) and x-ray photoemission spectroscopy (XPS) with circularly polarized x rays. Deposition of ultrathin Ni films on thin films of Co grown on Cu(001) results in an intensity enhancement across the Co L\textsubscript{2,3} absorption edge. By comparison, the intensity of the Ni L\textsubscript{2,3} edge decreases as a function of Ni film thickness. The relative changes in the Ni and Co XAS intensities are interpreted as an electronic charge transfer from the Co to the Ni. Distinct changes in the Co 2p XAS and XPS line shapes after addition of the Ni overlayer imply a modification of the Co 3d electron correlation due to the charge transfer. The change in the electronic structure is related to the interface magnetism using magnetic circular dichroism sum rule analysis. © 2000 American Institute of Physics. [S0021-8979(00)65308-2]

Recent developments in thin film growth technology have enabled the fabrication of novel materials with high potential for commercial application in the magnetic recording industry. In parallel with these advances, thin films have been investigated with the aim of understanding the changing electronic and magnetic structures as the film thickness is varied.\cite{1, 2, 3} X-ray absorption spectroscopy (XAS) and x-ray photoelectron spectroscopy (XPS) combined with circularly polarized synchrotron radiation are powerful techniques with which to probe the surfaces and interfaces of these thin films. XAS using circularly polarized radiation gives rise to x-ray magnetic circular dichroism (XMCD) which yields elementspecific spin and orbital magnetic moments.\cite{4, 5} On the other hand, magnetic circular dichroism in photoemission (MCDPE) is a highly surface sensitive tool which can be used to determine the surface dependence of the orbital moment.\cite{5}

The line shapes of isotropic and dichroic spectra can change dramatically for varying film thickness due to electron transfer and hybridization at the interface or due to 3d electron correlation effects. Srivistava et al.\cite{3} have shown that the thickness dependent density of 3d holes for Ni thin films grown on Cu(001) gives rise to a modified XAS line shape. Dürr et al.\cite{7} have used changes in XAS and XPS line shapes to correlate the electron localization with the magnetic ordering of ultrathin Mn films.

In the present study, charge redistribution at the Ni/Co interface and the effects of an evolving electronic structure on interface magnetism are investigated using core-level spectroscopies. The deposition of Ni onto a 4 ML Co film results in distinct changes in the Co 2p XAS and XPS line shapes due to modifications in the d electron correlation.

The Cu(001) substrate was prepared by repeated cycles of Ar\textsuperscript{+} ion bombardment and annealing to 700 K in ultrahigh vacuum (UHV). Low-energy electron diffraction and XPS indicated a highly ordered surface without C and O contamination. A 4 ML Co film was subsequently grown onto the Cu(001) at temperatures between 270 and 300 K followed by deposition of Ni at similar temperatures. The core-level measurements were done using 85% circularly polarized light at beamline ID12B of the European Synchrotron Radiation Facility (ESRF) in Grenoble. XPS spectra were recorded using a hemispherical analyzer in a normal emission geometry with the light incident at 60° to the surface normal. XAS spectra were recorded in total yield mode with the light incident at 45°. The XAS spectra were normalized to a constant edge jump to yield information on a per atom basis. Saturation effects are negligible for the geometry and thin films used in this study.\cite{8} The magnetic dipole term in the spin sum rule is negligible in the present study since the data were taken near the magic angle.\cite{9} All other experimental details are given elsewhere.\cite{10}

Figure 1 shows Co L\textsubscript{2,3} XAS spectra for a 4 ML Co film before (dashed line) and after (drawn line) the addition of 1 ML of Ni. The spectra show features due to electric-dipole transitions from the spin-orbit split 2p core levels to unoccupied s and d states. The addition of the Ni overlayer results in increased intensity across both edges and in the appearance of additional satellite features, marked by the arrows. The inset of Fig. 1 shows the Co L\textsubscript{2,3} integrated intensity for varying Ni coverages after background subtraction which removes the contributions due to transitions into the unoccupied s and continuum states. In order to show the rise in the integrated intensity per Ni/Co interface site, \Delta(AL\textsubscript{3}+AL\textsubscript{2}), the raw change in the integrated intensities was divided by the Ni film thickness. Without this procedure \Delta(AL\textsubscript{3} + AL\textsubscript{2}) would yield the average number of d holes for all Co coordinations in the film. The increase in the integrated intensity over the Co L\textsubscript{2,3} edge in Fig. 1 reflects the increase in the number of Co d holes (n\textsubscript{d}). Similar XAS spectra recorded for the Ni L\textsubscript{2,3} edge showed that the number of Ni d holes decreases with decreasing Ni thickness.\cite{10} The dramatic increase in n\textsubscript{d} (cf. inset of Fig. 1) after the Ni deposition
together with the decrease in the Ni d holes suggests a transfer of charge at the interface from Co to Ni. The removal of charge from the Co sites after the addition of the Ni ML also influences the d electron correlation which results in the appearance of the satellite features marked by the arrows in Fig. 1.

Figure 2(a) shows Co L\textsubscript{2,3} XMCD spectra recorded for a 4 ML film before (dashed line) and after (drawn line) the addition of 1 ML of Ni. The increase in the XMCD intensity in Fig. 2(a) clearly shows an increase in the Co spin moment. Sum rule analysis gives an increase in the Co spin moment from 1.4±0.1 \( \mu_B \) to 1.9±0.1 \( \mu_B \). The error bars account for approximations used in the derivation of the sum rules\textsuperscript{11} and systematic errors in the experimental data.

Figure 2(b) shows the XMCD spectra recorded for a 0.2 ML (dashed line) and 2 ML (drawn line) Ni film grown on a 4 ML Co film. The inset shows the integrated L\textsubscript{3} dichroism (\( \Delta L_3 \)) as a function of Ni film thickness. The increasing transfer of electronic charge per interface atom for decreasing Ni film thickness (cf. inset of Fig. 1) is seen to be correlated with a decrease in the Ni L\textsubscript{3} dichroism (cf. inset of Fig. 2(b)). Sum rule analysis of the XMCD spectra in Fig. 2(b) gives a Ni spin moment of 0.4±0.06 \( \mu_B \) and 0.22±0.06 \( \mu_B \) for the 2 and 0.2 ML films, respectively. The thickness dependent number of Ni d holes has been included in the calculation of the spin moments.\textsuperscript{3,10}

The transfer of charge from Co to Ni therefore increases the Co spin moment and reduces the Ni spin moment. In a one-electron model the charge redistribution will affect the exchange-split minority and majority bands and result in a modified magnetic structure at the interface. The precise mechanism of this process requires detailed first-principles calculations which reproduce the charge redistribution at the interface. However, our Korringa–Kohn–Rostoker Green’s function calculations invoking the local-spin-density approximation (LSDA) show no change in the d occupancy of the Ni or Co at the Ni/Co interface. Furthermore, these calculations also predict bulk values for the Ni and Co spin moments at the interface in agreement with previously reported calculations.\textsuperscript{12} The discrepancy between the experimental and theoretical results is most likely due to the limitations of the LSDA in accurately determining the spin dependent exchange-correlation energy for the ferromagnetic interface.

In a configuration interaction (CI) model, the origin of ferromagnetism in Ni metal has been explained in terms of a small d\textsuperscript{8} weight in the ground state.\textsuperscript{13,14} The transfer of charge will affect the d weights and therefore the spin moments. However, the application of the CI model to other transition metals is more complicated because of the increasing number of configurations involved. For the Ni, thickness dependent XAS and XMCD line shape changes show that the charge redistribution reduces the d\textsuperscript{8} weight and increases the diffuse magnetism arising from delocalized sp states.\textsuperscript{10}
The magnetic and electronic structure of the Ni/Co interface has been studied using core-level spectroscopy of ultrathin Ni films deposited on a 4 ML Co film. XAS and XMCD indicate a charge transfer from the Co to the Ni, during interface formation, which results in an increase in the Co spin moment and a reduction of the Ni spin moment. The line shapes of the Co XAS and XPS spectra are shown to be sensitive to the $d$ occupation and may be used to probe electron correlation effects in thin film interfaces induced by charge redistribution.

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